Docket No.: 5241-0107PUS1

The listing of claims will replace all prior versions, and listings, of claims in the

application.

1. (Currently Amended) A method of designing a molding die for molding an optical

device having a desirable form optimized so as to yield a desirable wavefront aberration by using

a plurality of optical parameters;

the method comprising the steps of:

designing by using at least the plurality of optical parameters, a temporary optical device

for optimizing a form so as to exhibit the desirable wavefront aberration;

making, according to the optimized form of the optical device, a temporary molding die

for molding the optical device;

molding a first temporary optical device by using the temporary molding die;

measuring a wavefront of thus molded first temporary optical device and calculating a

wavefront aberration amount Δ ;

calculating a correction wavefront aberration amount $-\Delta$ compensating for the wavefront

aberration amount Δ ;

designing a second temporary optical device by using at least the plurality of optical

parameters a second temporary optical device for optimizing a form so as to exhibit a wavefront

aberration with the correction wavefront aberration amount $-\Delta$ without using a table prepared

beforehand which shows a relationship between a deviation of the wavefront

aberration amount Δ and a deviation of the optical parameter; and

designing, according to the optimized form of the second temporary optical device, a

normal molding die for molding a normal optical device., wherein

calculating a correction wavefront aberration amount does not include comparing

wavefront aberration amount with a table prepared beforehand.

2. (Previously Presented) A method according to claim 1, further comprising the steps of:

molding the normal optical device by using the normal molding die;

measuring a wavefront aberration of thus molded optical device and calculating the

wavefront aberration amount; and

recalculating the correction wavefront aberration amount when the wavefront aberration

amount has a value greater than a predetermined reference value, and repeating subsequent steps

until the value of the wavefront aberration amount becomes the reference value or less.

3. (Previously Presented) A method according to claim 1, wherein the wavefront

aberration amount and correction wavefront aberration amount are calculated based on

measurements of an interferometer apparatus for measuring a transmitted wavefront.

4. (Original) A method according to claim 1, wherein a plurality of wavefront aberration

amounts are measured in a plurality of divided areas, respectively, and respective correction

wavefront aberration amounts are calculated for thus measured plurality of wavefront aberration

amounts.

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5. (Original) A method according to claim 1, wherein at least one surface of the optical device is an aspheric surface.

- 6. (Original) A method according to claim 1, wherein the optical device is a single lens, used for an optical pickup objective lens, having aspheric surfaces on both sides.
- 7. (Original) A method according to claim 1, wherein the molding die is used for press molding or injection molding.